PATENT

Docket No.: NAU-052

IN THE UNITED 3, 101113926. .... RADEMARK OFFICE &

7-26-99

## **RECORDING COVER SHEET**

Assignor:

Kun-Chih Wang

Chao-Ching Hsieh

2. Assignee: UNITED MICROELECTRONICS CORP.

No.3, Li-Hsin Road 2,

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Hsin-Chu, Taiwan, R.O.C.

Nature of Conveyance: Assignment of patent 3.

4. Reference number:

Application filed herewith. 09/36063

5. Correspondence to: Winston Hsu

3F, No. 52, Lane 46, Min-Sheng Rd.,

Yung-Ho City, Taipei Hsien,

Taiwan, R.O.C.

Number of applications affected by this recording: 1 6.

Total fee:  $(1 \times 40) = 40.00$  Payment by check enclosed Authorization is hereby given to charge the over payment to deposit account #500801

- Execution date of the document to be recorded: 07/14 /1999 7.
- Total number of pages including cover sheet: 3 8.
- 9. I declare under penalty of perjury that to the best of my knowledge and belief, the information contained on this cover sheet is true and correct, and that any copy submitted herewith is a true and correct copy of the original document.

Date: 2/15/1999

Winston Har

Winston Hsu U.S. Patent Agent Reg. No.:41,526

## **ASSIGNMENT OF INVENTION**

In consideration of the payment by ASSIGNEE to ASSIGNOR of the sum of One Dollar (\$1.00), the receipt of which is hereby acknowledged, and for other good and valuable consideration,

**ASSIGNORS (Inventors):** 

Name:	Kun-Chih Wang	Nationality:	R.O.C.
Address:	2F, No.52, Tung-Te 7 St., Tao-Yua	an Citv. Taiwan.	R.O.C.
Name:	Chao-Ching Hsieh	Nationality:	R.O.C.
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	Hsien, Taiwan, R.O.C.		
Name:		Nationality:	
Address:			
Name:		Nationality:	
Address:			
Hereby se	ells, assigns and transfers toUNITI	ED MICROELI	ECTRONICS CORP
(hereinaft	ter "Assignee"), of (Assignee address)	No.3, Li-Hsin	Road 2, Science-Based
Industri	al Park, Hsin-Chu, Taiwan, R.O.C.	_, and the succe	ssors assigns and lega
representa	atives of the ASSIGNEE the entire righ	t, title, and interes	est in and to any and al
improv	ements which are disclose	d in the inv	ention entitled
" Meth	od of forming a lower electrode of a ca	pacitor in a DRA	M cell "
****			
Which is			
` '	_ U.S. patent application executed on e		
` '	_ U.S. patent application executed on		
(c)	U.S. application serial no		
(d)	patent no.	issued	

Page 1 of 2

and, in and to, all Letters Patent to be obtained for said invention by the above application or ant continuation, division, renewal, or substitute thereof, and as to letters patent any reissue or re-examination thereof

ASSIGNOR hereby covenants that no assignment, sale, agreement or encumbrance has been or will be made or entered into which would conflict with this assignment;

ASSIGNOR further covenants that ASSIGNEE will, upon its request, be provided promptly with all pertinent facts and documents relating to said invention and said Letters Patent and legal equivalents as may be known and accessible to ASSIGNOR and will testify as to the same in any interference, litigation or proceeding related thereto and will promptly execute and deliver to ASSIGNEE or its legal representatives any and all papers, instruments or affidavits required to apply for, obtain, maintain, issue and enforce said application, said invention and said Letters Patent and said equivalents thereof which may be necessary or desirable to carry out the proposes thereof.

IN WITNESS WHEREOF, We have hereunto set hand and seal this \(\frac{17/14/99}{2}\) (Date of signing).

(Type name of inventor)	Signature of INVENTOR
Kun-Chih Wang	Kun- Efrila Wang
-	(1)
Chao-Ching Hsieh	Chao-Ching Hsieh